

Title (en)
CONTINUOUS TRIVALENT CHROMIUM PLATING METHOD

Title (de)
KONTINUIERLICHES VERFAHREN ZUR PLATTIERUNG MIT DREIWERDIGEM CHROM

Title (fr)
PROCÉDÉ DE PLACAGE AU CHROME TRIVALENT EN CONTINU

Publication
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Application
EP 15748593 A 20150209

Priority
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Abstract (en)
This invention belongs to the field of chemistry and metallurgy and it is specifically related to a process for the electrolytic and electrophoretic production of electrochemical coatings with a bath from trivalent decorative chromium solutions on a metal or plastic substrate with trivalent chromium ions, sulfate ions, graphite anodes, hexavalent chromium control and false cathode purifications in a continuous industrial operation.

IPC 8 full level
C25D 3/06 (2006.01)

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Cited by
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